

PATENT NUMBER

JCS29 U.S. PRO  
09/872203

**U.S. UTILITY Patent Application**

<p><b>O.I.P.E.</b></p> <p>SCANNED <i>15-3</i> Q.A. <i>JN</i></p>	<p><b>PATENT DATE</b></p>
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APPLICATION NO. 09/872203	CONT/PRIOR	CLASS 118 <del>427</del>	SUBCLASS 778	ART UNIT 1763 <del>1762</del>	EXAMINER <i>W. J. J. J. J.</i> <i>Col. G. J. J.</i>
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## APPLICANTS

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# TITLE

Method of forming a thin film using atomic layer deposition

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PTO-2040  
12/89

ISSUING CLASSIFICATION											
ORIGINAL				CROSS REFERENCE(S)							
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL CLASSIFICATION											

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<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>			<b>CLAIMS ALLOWED</b>	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)			<b>NOTICE OF ALLOWANCE MAILED</b>	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____	_____ (Primary Examiner) (Date)			<b>ISSUE FEE</b>	
				Amount Due	Date Paid
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)			<b>ISSUE BATCH NUMBER</b>	

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